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Prediction of new phase 2D C_{2h} group III monochalcogenides with direct bandgaps and highly anisotropic carrier mobilities†

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Two-dimensional (2D) group III monochalcogenides (MX, M = Ga, In and X = S, Se, Te) are promising candidates for next-generation ultrathin optoelectronic devices due to their exotic properties. However, the lack of direct band gaps and the low hole mobilities in their conventional single-layer D_{3h} phase hinder their potential utility for various applications. In this work, new polymorphs of 2D MXs belonging to the space group C_{2h} are predicted through a global structural search based on artificial swarm intelligence and density functional theory calculations. We demonstrate that such monolayer polymorphs are thermodynamically and kinetically stable through phonon spectrum analysis and *ab initio* molecular dynamics simulations. Direct band gaps of 2.38 to 2.84 eV are revealed in all C_{2h} MX monolayers, a property that traditional 2D D_{3h} MXs do not possess. Calculations based on the Boltzmann Transport Equation method show that electron mobilities in C_{2h} monolayers are significantly higher in magnitude than those of the conventional D_{3h} phase. Anisotropic optical properties are predicted and high absorption coefficients covering the UV-visible spectra are also reported. All these features render the new C_{2h} MX monolayers promising candidates for potential applications in high-efficiency solar cells and anisotropic optoelectronic devices.

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1. Introduction

Since the discovery of graphene by Novoselov and Geim in 2004, atomically thin 2D materials have been a focal point in the quest for next-generation flexible nanoelectronics and optoelectronics in the post-Si era.^{1–7} In addition to the well-known graphene-like group IV semiconductors and group III–V binary compounds,^{8–10} both experimental and theoretical investigations have expanded the 2D-semiconductor family by the discovery of monolayer group IV monochalcogenides,^{11,12} transition metal dichalcogenides,^{13,14} black phosphorus,^{15,16} and group III monochalcogenides.^{17–22} Nevertheless, the zero band gap in graphene,¹¹ low electron mobility in transition metal dichalcogenides,¹³ and the structural instability of black phosphorus under moisture conditions greatly restrict their applications.¹⁶ Therefore, novel 2D semiconductors with sizable band gaps, high carrier mobilities, and strong

stability are in great request. Fortunately, polymorphic properties in these single-layer materials provide new probability to realize this goal. Examples include the coexistence of metallic octahedral (1T') and semiconducting trigonal prismatic (2H) monolayer MoS_2 ^{23,24} as well as the presence of blue phosphorus with wider band gaps compared to the black phosphorus polymorphs.²⁵ Therefore, the exploration of monolayer polymorphs of known semiconductors leave room for the discovery of unexpected properties and emergent applications.

Among these 2D materials, group III monochalcogenides (MX), represented by InSe, have attracted growing research attention because of their idiosyncratic optoelectronic properties and their promising potential applications as field-effect transistors,^{17,21} photodetectors,^{26–28} and photocatalysts.³⁰ Significant efforts have also been spent on investigating the polymorphic nature of MXs. Take InSe as an example. Its most stable 2D structure takes a graphene-like honeycomb lattice, featured by a non-centrosymmetric D_{3h} point group.¹⁷ Bulk InSe consisting of D_{3h} layers are found to have a direct band gap of about 1.3 eV, but it increases to an indirect band gap of 2 eV as the sample thickness decreases to the atomic scale.²² Moreover, room-temperature hole mobility in D_{3h} monolayer InSe is only $4.8\text{ cm}^2\text{ V}^{-1}\text{ s}^{-1}$.²⁹ The lack of a direct band gap and the low hole mobility would severely restrict the optoelectronic applications of D_{3h} monolayer InSe. Recently, a new monolayer polymorph of InSe belonging to the

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D_{3d} point group has been theoretically predicted *via* the Particle Swarm Optimization (PSO) method, followed by the experimental synthesis of single-layer D_{3d} GaSe sheets.³¹ Although this new phase is reported to possess a wider band gap and a higher electron mobility,^{31,33} there are still some shortcomings that are not fully addressed, such as the absence of a direct band gap and the low hole mobility.

Here, we further explore the polymorphic nature of 2D MX semiconductors through artificial swarm intelligence computational structural searches on CALYPSO (Crystal structure AnaLYsis by Particle Swarm Optimization)³⁶ and *ab initio* calculations using the Vienna *ab initio* simulation package (VASP) software,^{37–40} and identified a monolayer phase belonging to the C_{2h} point group. It is reported that bulk C_{2h} InSe with a direct band gap has in fact been experimentally synthesized,^{34,35} which hints the possibility of fabricating C_{2h} monolayers whose properties were largely unknown. We demonstrate the thermodynamic and kinetic stability of the identified C_{2h} monolayers through phonon spectrum analyses and *ab initio* molecular dynamics (AIMD). We carried out first-principles computations on the electrical and optical properties of single-layer C_{2h} MXs and discovered that they all have intrinsic wide direct bandgaps located in the visible spectrum. Furthermore, anisotropic carrier mobilities are reported. It is noteworthy to point out that while C_{2h} MXs have electron mobilities that are comparable to those of conventional C_{2h} monolayers, their hole mobilities are significantly higher than those in D_{3h} sheets. Anisotropic optical properties of 2D C_{2h} MXs with higher linear absorption coefficients in the UV-visible spectra are also observed. Such superior properties render the C_{2h} III–VI binary 2D semiconductors worthwhile for further studies to shape them into promising candidates for high-performance electronics and optoelectronics.

2. Computational methods

Structural prediction through artificial swarm intelligence computational structure searches on CALYPSO (Crystal structure AnaLYsis by Particle Swarm Optimization)³⁶ is applied systematically to the most discussed binary MXs in the III–VI family, namely InSe, InS, GaSe, and GaS.^{17–32} Detailed information regarding this method can be found in the ESI.†

Ab initio molecular dynamics (AIMD) calculations were performed through the Vienna *ab initio* simulation package (VASP) software^{37–40} using the *NVT* ensemble in which the temperature was held constant at 300 K in the Nose–Hoover thermostats.⁴¹ All molecular dynamics (MD) calculations were performed on the $4 \times 4 \times 1$ supercells of single-layer MX compounds whose k -spaces were sampled by a $2 \times 2 \times 1$ grid, and all simulations applied a time step of 2 fs, lasting for 10 ps (5000 steps). The phonon dispersion spectra were obtained using density functional perturbation theory (DFPT) as implemented in PWscf (Quantum ESPRESSO package)^{42–44} with a planewaves cutoff of 60 Ry. A $20 \times 20 \times 1$ k -sampling and a $5 \times 5 \times 1$ phonon grid were utilized in the phonon dispersion calculations.

Density functional theory (DFT) calculations on the properties of 2D C_{2h} MXs were carried out based on the generalized gradient approximation (GGA) along with the exchange–correlation functional proposed by Perdew, Burke, and Ernzerhof (PBE)^{45,46} as implemented in VASP. The projected augmented-wave (PAW) pseudopotentials were utilized for the description of the electron–ion interactions in the systems,^{47,48} and an energy cutoff of 400 eV was adopted for the plane-wave basis set. For all calculations associated with the 2D structures and properties, a vacuum slab of 20 Å was inserted along the c -axis to avoid interactions between the periodic images on the perpendicular directions. For geometry optimizations and electronic structure calculations, $20 \times 20 \times 1$ Monkhorst–Pack meshes were applied to sample the Brillouin zone. The lattice structures and atomic positions were relaxed using the conjugated gradient method, and the equilibrium configurations of the systems are determined once the residual energy and force meet their convergence criteria, which are set to be 1×10^{-8} eV and 0.001 eV Å^{-1} respectively. The Heyd–Scuseria–Ernzerhof (HSE06) hybrid functional was adopted to obtain more accurate band structures.⁴⁹

The carrier mobilities were obtained using the EPW code based on the *ab initio* Boltzmann transport equation (BTE)⁵⁰ which expresses the mobility μ_e as

$$\mu_e = |e| \frac{\sum_{n \in \text{CB}} \int_{\text{BZ}} \tau(n, \mathbf{k}) v^2(n, \mathbf{k}) \left| \frac{\partial f(n, \mathbf{k})}{\partial E(n, \mathbf{k})} \right| d\mathbf{k}}{\sum_{n \in \text{CB}} \int_{\text{BZ}} f(n, \mathbf{k}) d\mathbf{k}},$$

where e is the electron charge. The summation is over the band index n , and the integrals are over the electron wavevector \mathbf{k} . For an electronic state denoted as (n, \mathbf{k}) , its energy is expressed as $E(n, \mathbf{k})$, and its lifetime is denoted as $\tau(n, \mathbf{k})$; its band velocity, expressed as $v(n, \mathbf{k})$, can be obtained *via* the gradient of the energy band in the k -space: $v(n, \mathbf{k}) = \frac{1}{\hbar} \nabla E(n, \mathbf{k})$; its occupation distribution at equilibrium ($f(n, \mathbf{k})$) is derived according to the Boltzmann distribution function: $f(n, \mathbf{k}) = \exp\left(\frac{E(n, \mathbf{k})}{k_B T}\right)$, where k_B and T are the Boltzmann constant and the system temperature respectively.

Carrier mobility computation using the EPW code also involves the calculation of the electron–phonon coupling (EPC) matrix.⁵¹ In our study, the EPC matrix elements were computed through DFPT calculations on a $100 \times 100 \times 2$ k -grid and a $100 \times 100 \times 2$ q -grid. Moreover, the carrier concentration was set to be 10^{13} cm^{-3} for all systems when calculating the mobilities.

Carrier effective mass is calculated using the following equation:

$$m^* = \hbar^2 \left(\frac{d^2 E}{dk^2} \right)^{-1},$$

where $\frac{d^2 E}{dk^2}$ is the curvature of the electronic band.

The optical absorption coefficients of the MXs are derived from the frequency-dependent complex dielectric function



calculated with the HSE06 method:

$$\varepsilon(\omega) = \varepsilon_{\alpha\beta}^{(1)}(\omega) + i \cdot \varepsilon_{\alpha\beta}^{(2)}(\omega),$$

where $\varepsilon_{\alpha\beta}^{(1)}(\omega)$ and $\varepsilon_{\alpha\beta}^{(2)}(\omega)$ stand for the real and imaginary part of the dielectric function, respectively. With the complex dielectric function at hand, the absorption coefficient (α) can be derived from the following equation:

$$\alpha(\omega) = \sqrt{2}\omega \left[\sqrt{\varepsilon_{\alpha\beta}^{(1)2}(\omega) + \varepsilon_{\alpha\beta}^{(2)2}(\omega)} - \varepsilon_{\alpha\beta}^{(1)}(\omega) \right]^{1/2}.$$

3. Results and discussion

3.1. Structural search

After unbiased global structural searches based on the PSO algorithm, 3600 possible structures per MX compound are sampled from the free energy landscape, and the ones among them with relatively low energies are mainly composed of three monolayer polymorphs. Structural predictions of InSe in our study are consistent with the results reported in Zhang's study.³¹ The lowest-energy structure (Fig. 1a) corresponds to the experimentally known D_{3h} monolayer. Another polymorph belonging to the D_{3d} space group is found to have an energy comparable to that of the D_{3h} structure, which has been thoroughly explored in Zhang's study.³¹ The D_{3d} phase is beyond the scope of our study, thus not discussed here. The polymorph shown in Fig. 1b is a monoclinic lamellae phase belonging to the C_{2h} point group. Distinct from the conventional D_{3h} phase with four atoms per unit cell, the C_{2h} phase features a larger unit cell in which eight atoms are included.

The lattice constants of the fully relaxed MX monolayers predicted by CALYPSO are tabulated in Table 1. For 2D C_{2h} InSe, its optimized lattice parameters are $a = 11.23$ Å, $b = 4.10$ Å, which show significant similarity to the experimental data of the bulk sample ($a = 11.74$ Å, $b = 4.11$ Å).³³ Since the C_{2h} phase

Table 1 The lattice constants (a and b) of D_{3h} and C_{2h} MXs and their corresponding cohesive energies (E_c)

		a (Å)	b (Å)	E_c (eV per atom)
InSe	D_{3h}	4.08	4.08	3.543
	C_{2h}	11.23	4.10	3.504
InS	D_{3h}	3.93	3.93	3.847
	C_{2h}	11.08	3.97	3.810
GaSe	D_{3h}	3.81	3.82	3.795
	C_{2h}	9.97	3.82	3.746
GaS	D_{3h}	3.63	3.63	4.158
	C_{2h}	9.81	3.65	4.109

of these compounds except for InSe has not been studied before, there are no theoretical or experimental data in previous literature to compare with. Data in Table 1 indicate that the lattice constants b are approximately the same for both of the D_{3h} and C_{2h} phases while the lattice parameters a in C_{2h} MXs are about three times larger than those in D_{3h} monolayers. As shown in Fig. 1b, the vertically aligned M–M bonds in the D_{3h} phase adopt a nearly horizontal orientation in the C_{2h} unit cell, making the latter phase distinct from the graphene-like honeycomb lattice of the former one (Fig. 1a). This structural feature also endows the C_{2h} structure with potential anisotropic properties along the horizontal axes. Moreover, the presence of inversion symmetry in the C_{2h} phase differentiates itself from the non-centrosymmetric D_{3h} phase.

3.2. Thermodynamic and kinetic stability

Cohesive energy (E_c) calculations are carried out based on the following expression, and the corresponding data are recorded in Table 1.

$$E_c = [(N_M E_M + N_X E_X) - E_{MX}] / (N_M + N_X),$$

where N_M and N_X are the number of group III (M) and VI (X) atoms per unit cell respectively, while E_M and E_X stand for the single atom energies of their corresponding elements, and E_{MX} is the system's total energy. It is indicated in Table 1 that there is an energy difference of about 40 to 50 meV per atom between the energetically less favored C_{2h} polymorph and the common D_{3h} phase for all III–VI compounds. This difference in cohesive energy for GaX compounds (49 meV per atom for both GaSe and GaS) is larger than that in InX compounds (39 meV per atom for InSe and 37 meV per atom for InS). More importantly, these energy differences can be considered tolerable compared to that between the 2H and 1T phases of MoS_2 (≈ 70 meV per atom).⁵² This suggests that the monolayer C_{2h} phase could possibly be fabricated experimentally given their favorable energetics.

Thermodynamic and kinetic stability of C_{2h} MX monolayers under ambient conditions is demonstrated *via* AIMD computations and phonon dispersion spectra. For all four MX compounds of interest, AIMD simulation results of monolayer D_{3h} and C_{2h} phases are demonstrated respectively in Fig. S1 (ESI[†]) and Fig. 2. For the entire simulation processes, all atoms vibrate around their equilibrium lattice sites without causing structural disorders. As shown in Fig. 2, the fluctuations in potential energies of the

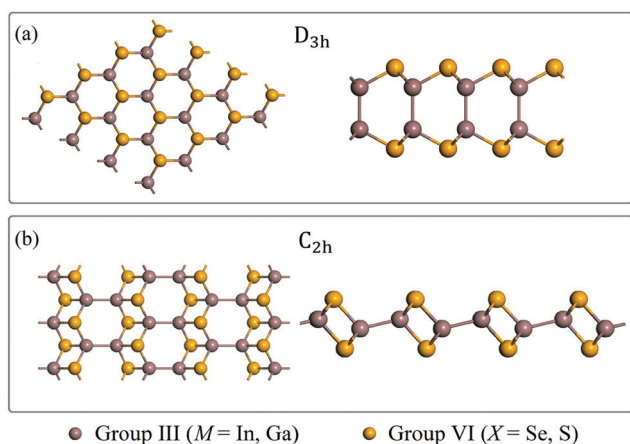


Fig. 1 The monolayer structures of (a) D_{3h} and (b) C_{2h} MXs. The top and side views are presented on the left and the right side of each panel respectively. The structural coordinates of C_{2h} monolayers can be found in the ESI.[†]



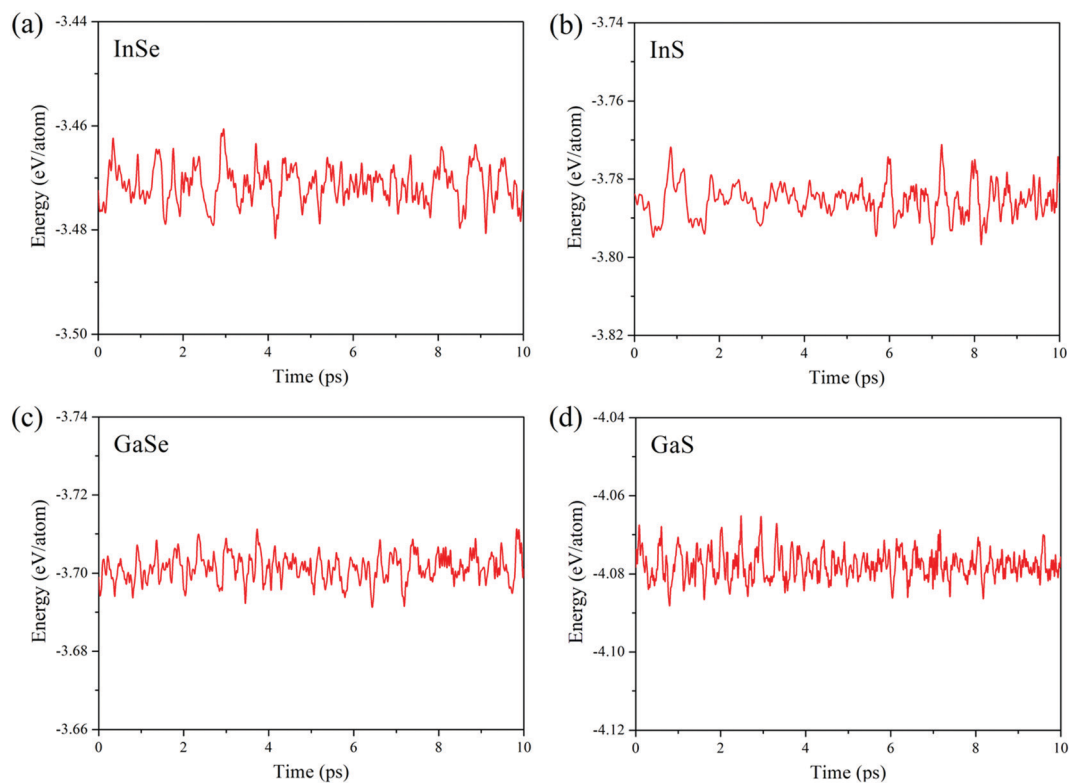


Fig. 2 Fluctuations of the potential energies of monolayer C_{2h} (a) InSe, (b) InS, (c) GaSe, and (d) GaS during the process of molecular dynamics under a temperature of 300 K.

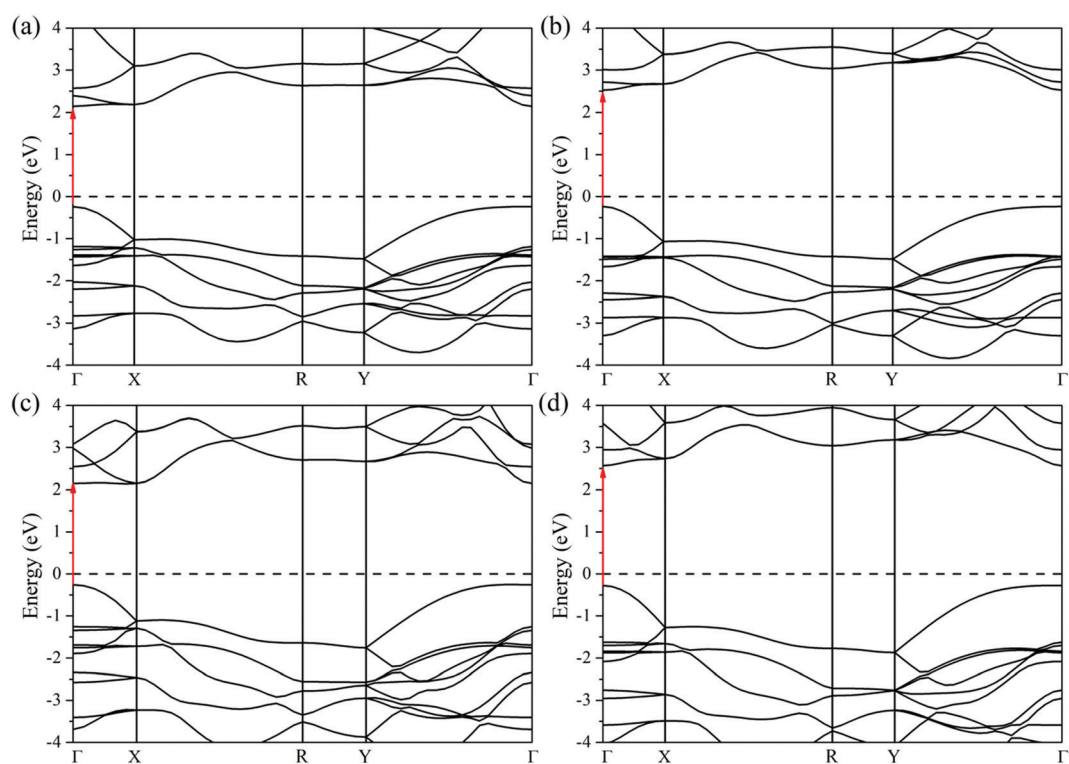


Fig. 3 Computed electronic band structures of monolayer C_{2h} (a) InSe, (b) InS, (c) GaSe, and (d) GaS at the HSE06 level. The red arrows point from VBM to CBM (direct band gaps at the Γ points). The values of the band gaps can be found in Table S1 (ESI†).



C_{2h} monolayers maintain within approximately 0.03 eV per atom. The M–M and M–X covalent bonds in the C_{2h} lattice demonstrate high strength and restrain the structures from undergoing phase transitions. Moreover, phonon dispersion analyses are performed, and phonon spectra are calculated in the PWscf section of Quantum ESPRESSO. As shown in Fig. S2 (ESI[†]), the absence of imaginary vibrational modes throughout the Brillouin zone (Fig. S3, ESI[†]) confirms the dynamical stability of the monolayer C_{2h} lattices.

3.3. Electronic properties

Calculated electronic band structures at the HSE06 level are demonstrated in Fig. 3. The conduction band minima (CBM) and valence band maxima (VBM) for all monolayer C_{2h} MXs occur at the Brillouin zone center (Γ symmetry point), indicating that all of them exhibit direct band gap characteristics. The energetic gaps of C_{2h} monolayer InSe, InS, GaSe, and GaS are 2.38, 2.78, 2.39, and 2.84 eV respectively, located in the visible spectrum. Comparing the band gap of the single-layer C_{2h} InSe to that of the bulk sample (a direct bandgap of 1.647 eV reported by Ghalouci *et al.*),³⁴ a significant gap broadening of 0.73 eV is observed due to the quantum-confinement effect when the thickness of the material is down to the atomic level.²² This conclusion could be applied to other MXs as well.

As shown in Fig. 4 and Table S2 (ESI[†]), while the conduction band edge of D_{3h} InSe monolayer has approximately equal contribution from In and Se (51.8% In and 48.2% Se), that of 2D C_{2h} InSe is dominated by In (71.0% In and 29.0% Se). This finding can also be applied to the other three MX monolayers. Such different band-edge states in C_{2h} MXs might give rise to exceptional electronic properties. It is also critical to emphasize that among all four single-layer MXs, C_{2h} polymorph is the only phase that features a direct band gap, a property that the conventional D_{3h} monolayers never possess. The origin of this extraordinary electronic property could be found in the band structures and the projected density of states (PDOS) diagrams. To begin with, just like what plenty of previous studies indicated, the single-layer D_{3h} InSe features a non-parabolic “Mexican hat” shaped structure at the top of the valence band as shown in Fig. 4a.^{21,53} This unique band structure occurs when the material is thinned down from its bulk form to a single layer. The same “Mexican-hat” band edge occurs in other D_{3h} MX monolayers as well, as shown in Fig. S5 (ESI[†]).

The band structures of the bulk D_{3h} MXs feature a direct band gap in which both the VBM and CBM locate at the Γ point, but during the process of thinning down, the top of the valence band at the Γ point shifts downward until it forms a double-peak shape.^{21,53} As a result, the VBM migrates away from the Γ point and converts the direct band into an indirect one. Such “Mexican hat” band structure of InSe results in a 2D van Hove singularity which is visible as a sudden peak of density of states right below the Fermi energy (Fig. 4a).⁵³ Similar phenomena are observed in our calculated band structures for all monolayer D_{3h} MXs besides InSe, and sudden increases in the density of states are found near the top of the valence bands, contributed mainly by the p_z orbitals (shown in orange), according to our calculated PDOS diagrams (Fig. S5, ESI[†]). However, in comparison, the top of valence bands at the Γ points of the 2D C_{2h} MXs remain parabolic in nature (Fig. 4); there is no “Mexican hat” structure at the top of the valence bands. Thus, the VBMs remain at the Γ points, and the direct band features are maintained. At the VBMs of the C_{2h} monolayers, the PDOS's in Fig. 4 and Fig. S5 (ESI[†]) also reveal a lack of the sudden peak of density of states that is associated with the van Hove singularity in D_{3h} monolayers. In fact, the PDOS diagrams unveil that there are still sudden increases in the density of states contributed by the p_z orbitals in C_{2h} MXs between about -1.3 to -1.8 eV as shown in Fig. 4 and Fig. S5 (ESI[†]). However, the p_z orbitals are no longer dominating the top valence bands in C_{2h} monolayers; instead, they are rather lower in energy compared to the $p_{x/y}$ orbitals which now compose the topmost valence bands. The unique appearance of the latter in the C_{2h} phase overshadows the influence of the “Mexican-hat” shaped band responsible for the direct-indirect transition in the 2D D_{3h} polymorphs, and thus retains the direct band gap feature in the monolayer C_{2h} MXs. We also consider the effect of spin-orbit coupling (SOC) on the electronic band structures (Fig. S6, ESI[†]). Small differences between the band structures with and without SOC indicate its weak and negligible influence.

We also explore the transport properties of the 2D C_{2h} MXs based on the *ab initio* Boltzmann transportation equation (BTE) method. Carrier mobilities of all four MX monolayers belonging to both D_{3h} and C_{2h} space groups are calculated and tabulated in Table 2; their corresponding effective masses are reported in Table S3 (ESI[†]). The validity of our computation is tested since our calculated room-temperature electron mobility of 2D D_{3h} InSe ($136 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$) is similar to that reported in the study by

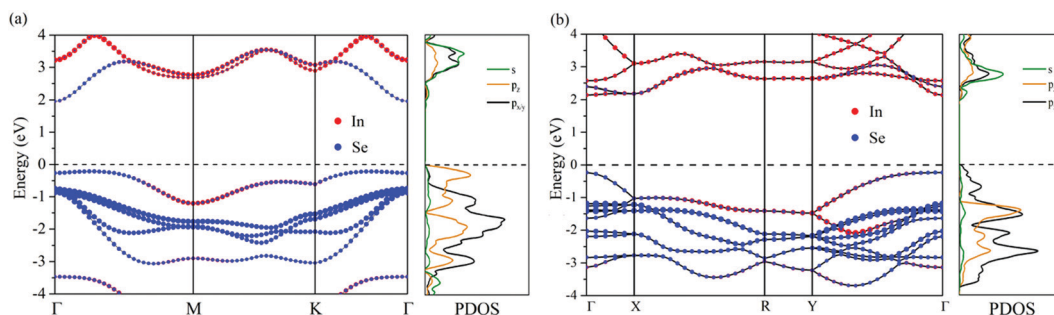


Fig. 4 A close comparison between the projected band structures (computed at the HSE06 level) of monolayer (a) D_{3h} and (b) C_{2h} InSe.



Table 2 Computed carrier mobilities (μ_e for electrons and μ_h for holes) of both single-layer D_{3h} and C_{2h} MXs along x - and y -direction at 100 K and 300 K

		μ_e (cm ² V ⁻¹ s ⁻¹)				μ_h (cm ² V ⁻¹ s ⁻¹)			
		100 K		300 K		100 K		300 K	
		x	y	x	y	x	y	x	y
InSe	D_{3h}	378	378	136	136	6.4	6.4	4.8	4.8
	C_{2h}	134	528	23	149	239	21	67	9.7
InS	D_{3h}	239	239	66	66	4.5	4.5	3.3	3.3
	C_{2h}	856	885	64	186	533	25.8	120	10.6
GaSe	D_{3h}	404	404	168	168	22	22	9	9
	C_{2h}	397	859	39	180	372	123	65	20
GaS	D_{3h}	421	421	209	209	3.9	3.9	2.2	2.2
	C_{2h}	78	128	25	77	80	6.9	28	4.7

Li *et al.* (120 cm² V⁻¹ s⁻¹).⁵⁴ According to Table 2, except for GaS, all four C_{2h} MX monolayers exhibit higher electron mobilities along the y -direction compared to their corresponding D_{3h} counterparts at 300 K. However, electron mobilities along the x -direction are comparatively lower in C_{2h} MXs than in D_{3h} monolayers, which can be attributed to the larger effective masses ($m_{e,x}^*$) in the former ones, as shown in Table S3 (ESI†). For example, compared to the electron mobility of 2D D_{3h} InSe (136 cm² V⁻¹ s⁻¹) monolayer C_{2h} InSe exhibits lower mobilities

in the x -direction (23 cm² V⁻¹ s⁻¹). Correspondingly, the electron effective mass along the x -direction in monolayer C_{2h} InSe (0.743 m_0) is higher than that in single-layer D_{3h} InSe (0.190 m_0), suggesting that it might be the heavier electron effective mass that results in a lower mobility. On the other hand, hole mobilities along both in-plane directions in 2D C_{2h} MXs are prominently higher than those in the D_{3h} phase. While hole mobilities along the y -direction ($\mu_{h,y}$) in the C_{2h} phase is about two to three times greater than those in the D_{3h} monolayers (e.g., $\mu_{h,y}$ = 9.7 cm² V⁻¹ s⁻¹ and 4.8 cm² V⁻¹ s⁻¹ in C_{2h} and D_{3h} InSe, respectively), $\mu_{h,x}$ in the former phase could be up to one order of magnitude higher than those in the latter (e.g., $\mu_{h,x}$ = 67 cm² V⁻¹ s⁻¹ and 4.8 cm² V⁻¹ s⁻¹ in C_{2h} and D_{3h} InSe, respectively). This phenomenon could be explained by the much smaller densities of states near the valence band edges of the C_{2h} monolayers, a parameter identified by Li *et al.*⁵⁴ as the key factor influencing the hole mobility in 2D materials. As mentioned before, the “Mexican-hat” shaped valence band edge in a D_{3h} monolayer MX gives rise to a sharp peak (van Hove singularity) in the density of states which increases the hole scattering rate, decreasing the carrier lifetime and the mobility. However, the lack of a similar peak in density of states associated with the van Hove singularity at the VBM of a C_{2h} monolayer spares the holes from a high probability of scattering, thus

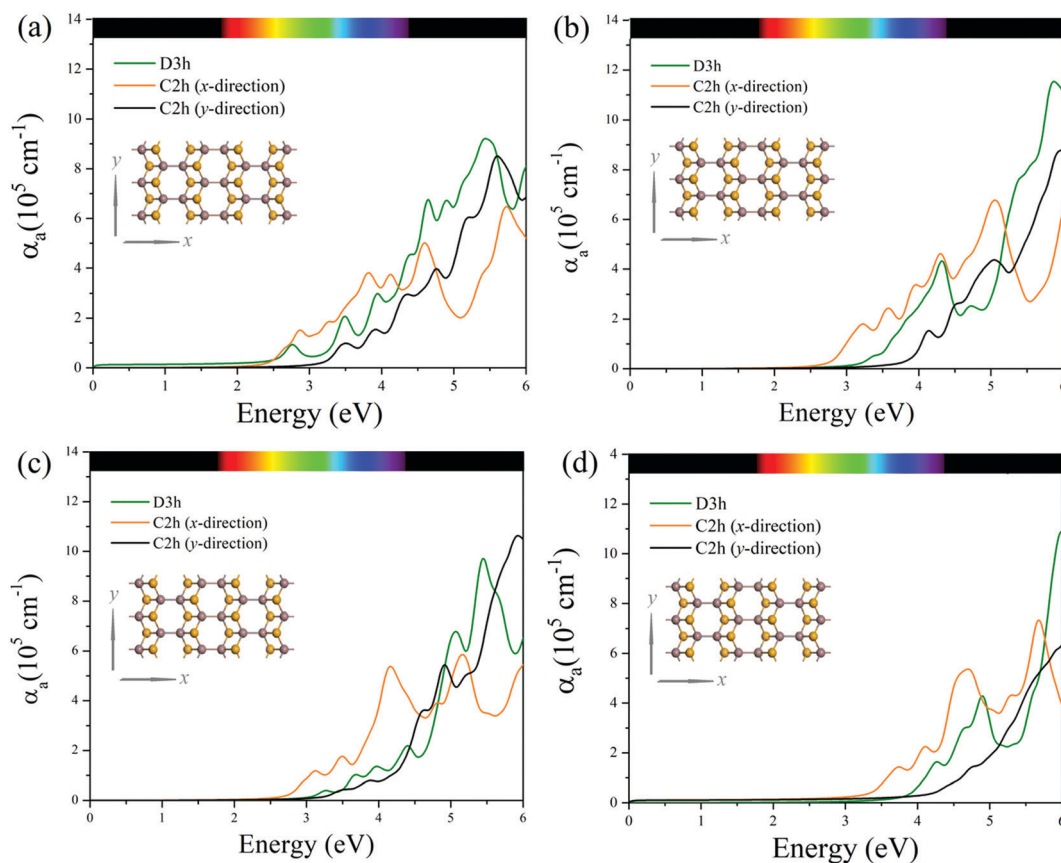


Fig. 5 Calculated absorption coefficients (α_a) in monolayer (a) InSe, (b) InS, (c) GaSe, and (d) GaS. The isotropic absorption coefficients of the D_{3h} phases are shown in green. For the C_{2h} monolayers, the absorption coefficients along the x -direction are shown in orange and those along the y -direction are shown in black. The insets show the two in-plane directions with respect to the top view of the C_{2h} structure.



extending the carrier lifetime and maintaining a high hole mobility. But what really makes C_{2h} monolayers stand out is their strong anisotropic characteristic, featuring higher electron mobilities along the y -direction and higher hole mobilities along the x -direction. In other words, the dominant transport direction in monolayered C_{2h} MXs exhibits a strong dependency on the carrier type. This property renders single-layer C_{2h} MXs suitable materials in nanoelectronics devices in which the superior transport direction can be readily altered by a change of carriers induced by switching the sign of the applied gate voltage. The anisotropic transport property might be contributed by different effective masses of the carriers along x - and y -directions, as shown in Table S3 (ESI†). Take C_{2h} InSe as an example. On one hand, while its hole effective mass along the y -direction is as high as $4.02 m_0$, that in the x -direction is approximately an order smaller, having a value of $0.304 m_0$. Correspondingly, the hole mobility in the x -direction ($67 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$) is almost one magnitude greater than that in the y -direction ($9.7 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$). On the other hand, a lower electron mobility along the x -direction ($23 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$ and $149 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$ in the x - and y -direction respectively) corresponds to a larger effective mass ($0.743 m_0$ and $0.216 m_0$ in the x - and y -direction respectively).

3.4. Optical properties

The optical properties of C_{2h} MXs monolayers are demonstrated and compared to those of their corresponding conventional D_{3h} polymorphs in their optical absorption spectra along x - and y -directions as shown in Fig. 5. Prominent optical absorption coefficients (on the order of 10^5 cm^{-1}) are observed in all C_{2h} MXs monolayers in the range of visible-UV lights. Especially when comparing the x -direction absorption spectra of C_{2h} (orange curves in Fig. 5) and D_{3h} (green curves in Fig. 5) MXs, the former exhibits significantly stronger absorption of visible and near-ultraviolet light than the latter does (approximately two times the latter in the range of 2 to 3 eV), implying a higher utilization efficiency of solar energy in C_{2h} MXs. The absorption spectra (Fig. 5) also indicate the conspicuously anisotropic optical characteristics of 2D C_{2h} MXs materials which are never found in their traditional D_{3h} phases. More specifically, along the x -direction of 2D C_{2h} MXs (orange curves in Fig. 5), absorption is much stronger in the visible and the near-ultraviolet but is significantly weaker as the energy further increases in the ultraviolet range when compared to that in the y -direction (black curves in Fig. 5). This intrinsic optical anisotropy of C_{2h} MXs monolayers endows themselves with promising potential for anisotropic optoelectronic applications.

4. Conclusions

To summarize, properties of single-layer C_{2h} group III monochalcogenides are predicted. We identified the stable 2D C_{2h} polymorph *via* global structural searches based on the particle swarm optimization algorithm. Notably, first-principles investigations on the electronic structures indicate that all C_{2h} monolayer MXs feature a wide direct bandgap ranging from

2.38 to 2.84 eV, a property that the conventional D_{3h} phase does not possess. In addition, carrier mobilities in C_{2h} monolayers are found to be anisotropic and higher in magnitude compared to their D_{3h} counterparts. Moreover, anisotropic and strong optical absorption ability in the order of 10^5 cm^{-1} is observed in the visible to ultraviolet region, indicating a high utilization efficiency of solar energy. All these excellent properties render the C_{2h} MXs monolayers potential candidates for future high efficiency solar cells and optoelectronics.

Conflicts of interest

There are no conflicts to declare.

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